



## PATENT APPLICATION

RESPONSE UNDER 37 CFR §1.116 **EXPEDITED PROCEDURE TECHNOLOGY CENTER ART UNIT 1753** 

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Satoshi TATSUURA et al.

Application No.: 10/082,228

Filed: February 26, 2002

Group Art Unit: 1753

Examiner:

E. Wong

Docket No.: 106200.01

METHOD FOR ELECTRODEPOSITED FILM FORMATION, METHOD FOR For:

ELECTRODE FORMATION, AND APPARATUS FOR ELECTRODEPOSITED FILM

FORMATION

## AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1.116

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In reply to the July 14, 2004, Office Action, please consider the following:

Amendments to the Claims as reflected in the listing of claims; and

Remarks.